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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/689,187	10/20/2003	N. Johan Knall	MA-002-1-I-a	2700
7590 06/09/2005 MATRIX SEMICONDUCTOR 3230 Scott Blvd Santa Clara, CA 95054			EXAMINER DOLAN, JENNIFER M	
			ART UNIT 2813	PAPER NUMBER

DATE MAILED: 06/09/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)	
	10/689,187	KNALL ET AL.	
	Examiner	Art Unit	
	Jennifer M. Dolan	2813	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 04 April 2005.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1 and 2 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1 and 2 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Claim Rejections - 35 USC § 103

1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

2. Claims 1-2 are rejected under 35 U.S.C. 103(a) as being unpatentable over U.S. Patent No. 4,881,114 to Mohsen et al. in view of U.S. Patent No. 5,835,396 to Zhang.

Mohsen discloses a memory array (figures 6, 7) disposed above a substrate (10), the array comprising a plurality of memory cells (figures 1, 2), each cell comprising a silicon nitride antifuse (14; column 4, lines 21-25), the array further comprising p+n- diodes or p-n+ diodes (column 3, lines 45-55; “moderately doped” layer 12 and “heavily doped” layer 16 form diode).

Mohsen fails to disclose that the memory array is a three dimensional multi-level array.

Zhang discloses three dimensional multi-level memory arrays having units substantially similar to that of Mohsen (figures 1, 13; column 2, lines 20-50; column 5, lines 45-50; column 6, lines 1-10; 55-60).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the memory cell array of Mohsen, such that it is formed in a three dimensional, multi-level array, as suggested by Zhang. The rationale is as follows: A person having ordinary skill in the art would have been motivated to use a three dimensional array,

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because doing so allows for an increase in memory density of the structure (Zhang, column 1, lines 60-67; column 2, lines 22-48).

Response to Arguments

3. Applicant's arguments filed 4/4/05 have been fully considered but they are not persuasive.

Regarding the combination of Mohsen and Zhang, the Applicant argues that “layer 12 of the device of Mohsen is formed in substrate 10, which those skilled in the art would assume to be a monocrystalline silicon wafer. Thus at least one part of the diode of Mohsen et al. comprises monocrystalline silicon.”

This assumption, however, is directly contradicted by the specification of Mohsen. Mohsen states, “Both of the semiconductor materials used to form electrodes 12 and 16 may be made up of a high electromigration immunity material. They may be formed from heavily doped polysilicon, or heavily doped single crystal silicon or a metal or a sandwich of a metal and heavily doped polysilicon in the alternative embodiment” (Mohsen, column 4, lines 4-10). Mohsen teaches structures including a metal electrode/SiN antifuse/metal electrode; polysilicon electrode/SiN antifuse/polysilicon electrode, or metal electrode/polysilicon layer/SiN antifuse/polysilicon/metal electrode in addition to structures using monocrystalline silicon. Thus, the Applicant's arguments about the feasibility of combining Mohsen and Zhang due to problems with producing deposited monocrystalline silicon layers are moot.

Furthermore, the Examiner maintains that a combination of Mohsen and Zhang is reasonable, since the metal/antifuse/metal or metal/polysilicon/antifuse/polysilicon/metal structures suggested in Mohsen are substantially similar to the memory cell units taught in Zhang, and therefore should be stackable in the same manner as Zhang in order to achieve the same benefits of increased memory density. Alternately, since Mohsen shows that SiN is a known antifuse material that may be used between any of metal, polysilicon, or monocrystalline silicon layers, it would be considered reasonable and well within the purview of a person having ordinary skill in the art to use SiN as the antifuse layer in the structure of Zhang.

Regarding the combination of Zhang and Takagi, although it is the Examiner's opinion that the properties of the SiN antifuse as presented in Takagi would generally be considered acceptable or beneficial properties for use in the three-dimensional memory of Zhang, the Examiner concedes that it is not reasonable to combine a programmable memory structure with a programmable gate array structure. Thus, the rejections based on a combination of Zhang and Takagi have been dropped.

Conclusion

4. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

- a. U.S. Patent No. 6,111,302 to Zhang et al. teaches that SiN, amorphous Si, SiO, and SiON may all be used interchangeably as antifuse materials.
- b. U.S. Patent No. 5,625,220 to Liu et al. teaches a SiN/SiON stacked antifuse.

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- c. U.S. Patent No. 5,682,059 to Yoshii et al. teaches that a SiN antifuse is usable for either a programmable memory or a programmable gate array.

5. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire **THREE MONTHS** from the mailing date of this action. In the event a first reply is filed within **TWO MONTHS** of the mailing date of this final action and the advisory action is not mailed until after the end of the **THREE-MONTH** shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than **SIX MONTHS** from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jennifer M. Dolan whose telephone number is (571) 272-1690. The examiner can normally be reached on Monday-Friday 8:30am-5:00pm.

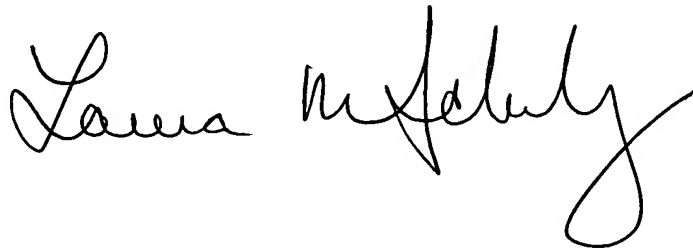
If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl W. Whitehead, Jr. can be reached on (571) 272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jennifer M. Dolan
Examiner
Art Unit 2813

jmd

A handwritten signature in black ink, appearing to read "Jennifer M. Dolan", with a large, stylized loop at the end of the last name.